

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

IN RE APPLICATION OF: Aelan MOSDEN et al. :

SERIAL NO.: 10/801,571

FILED: March 17, 2004

: ATTENTION  
: LICENSING & REVIEW  
:  
:

For: METHOD AND SYSTEM FOR TREATING A HARD MASK TO IMPROVE ETCH CHARACTERISTICS

**PETITION FOR LICENSE FOR FOREIGN FILING  
UNDER 35 U.S.C. 184 - EXPEDITED HANDLING**

COMMISSIONER FOR PATENTS  
Alexandria, VA 22313

SIR:

10/801,571  
Applicant hereby respectfully petitions the Patent Office under 37 C.F.R. 5.12(b) and 5.13 for a license under 35 U.S.C. 184 to permit petitioner to file or cause to be filed in foreign countries applications corresponding to the above-identified application. A copy of the specification is attached hereto.

It is believed that no section of 35 U.S.C. 181 is applicable.

The required fee set forth in 37 C.F.R. 1.17(h) of \$130.00 is also enclosed herewith.

**EXPEDITED PROCESSING IS REQUESTED.**

Please telephone Ms. Bette Snyder, at (703) 412-6237 when the license has been granted

and is ready to be picked up and a messenger from our office will be immediately dispatched.

Respectfully submitted,

OBLON, SPIVAK, McCLELLAND  
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